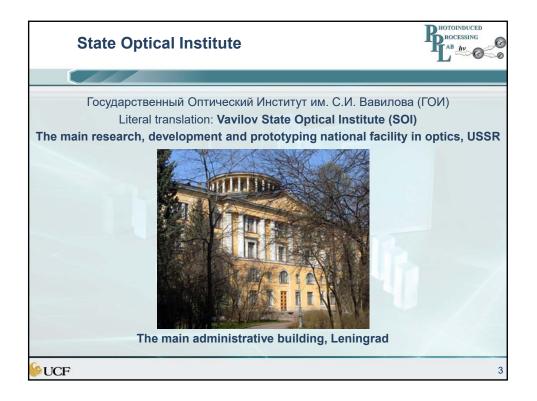
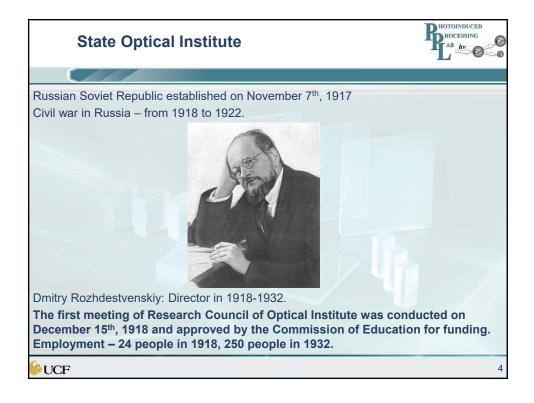
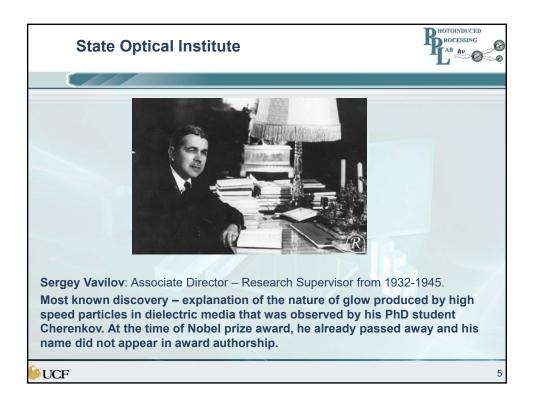
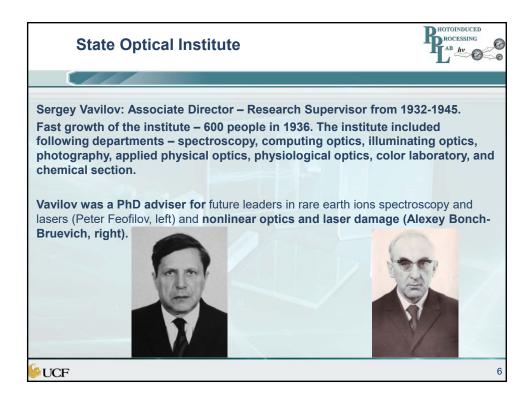


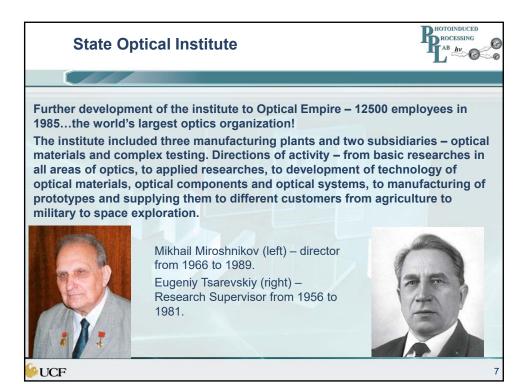
Laser-Induced Damage in Optical Materials 2018: 50th Anniversary Conference, edited by Christopher Wren Carr, Gregory J. Exarhos, Vitaly E. Gruzdev, Detlev Ristau, M.J. Soileau, Proc. of SPIE Vol. 10805, 1080506 © 2018 SPIE · CCC code: 0277-786X/18/\$18 · doi: 10.1117/12.2502569

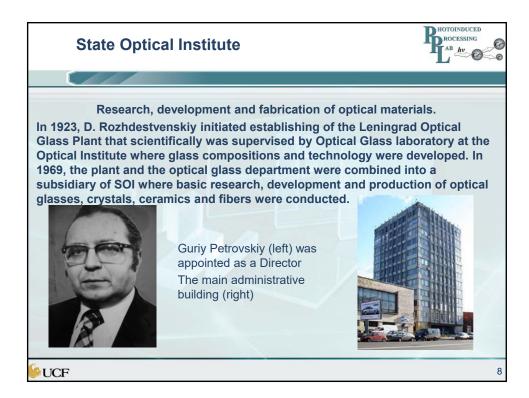




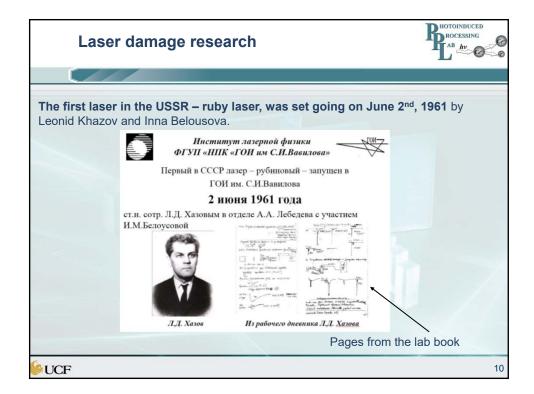


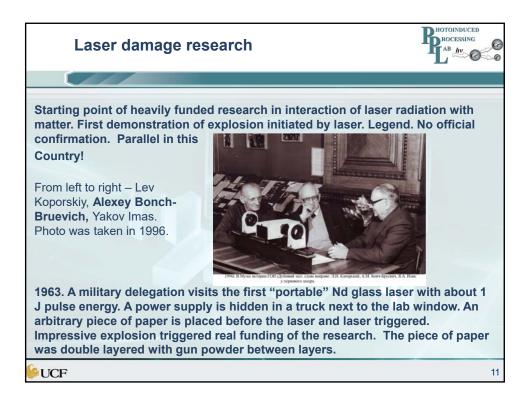


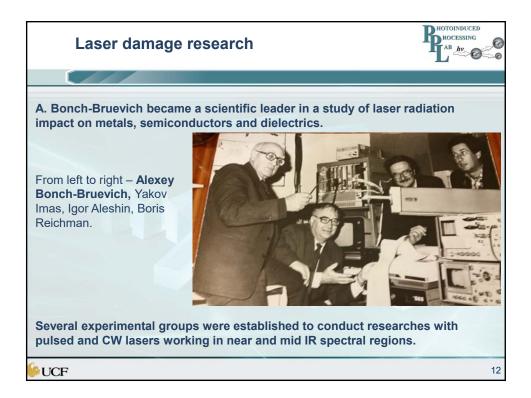




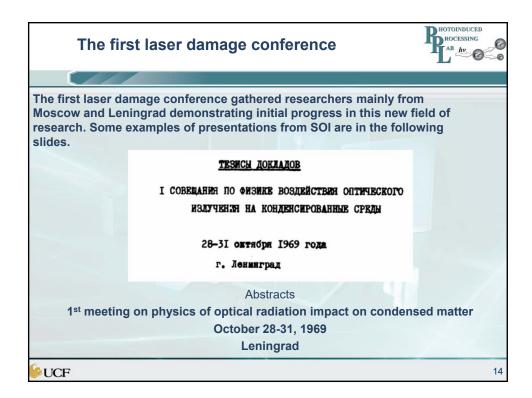


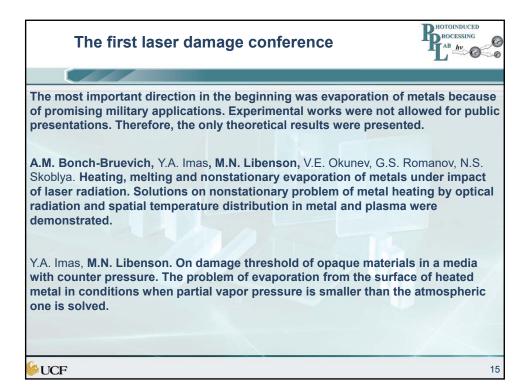




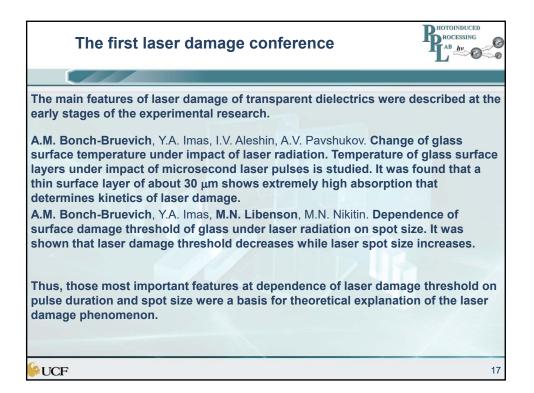


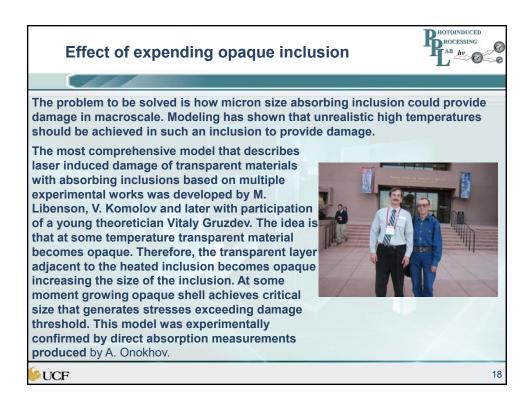












Optical materials for high power applications

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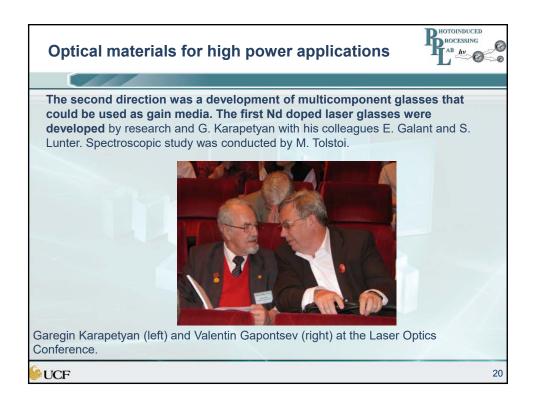
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While the main cause of low laser damage threshold for pulsed radiation was the presence of micron sized absorbing inclusions and for CW radiation – bulk absorption, technologies for optical materials with no inclusions and low bulk absorption were developed at the optical material subsidiary.



Two directions were explored at the time. The first one is vitreous silicon oxide produced by precipitation from a gas phase resulted from burning SiCl₄ in oxygen. This material was produced with diameters up to 500 mm and it became the main material for passive optical elements in high power laser systems. No inclusions, absorption at the level of few dB/km and low nonlinear refractive index made it suitable for both CW and short pulse lasers. Yuriy Kondratiev supervised this research and development.

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Successful demonstration of glass laser applications for range finders and laser fusion resulted in establishing laser glass laboratory managed by M. Tolstoi (a former PhD student of P. Feofilov) . Extra to development of laser glasses, he committed to develop a technology of high purity multicomponent glass with no inclusion and to study mechanisms of glass stability under impact of UV radiation of pump sources and under exposure to pulsed laser radiation to his PhD student **Leonid Glebov** and a researcher Lia Popova.



M. Tolstoi (left) and L. Glebov (right) with a cryogenic Nd glass laser

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